INTERNATIONAL STANDARD

ISO 13779-3

> Second edition 2018-12 AMENDMENT 1

Implants for surgery — Hydroxyapatite —

Part 3:

Chemical analysis and characterization of crystallinity ratio

iTeh STANDARD PREVIEW (stAMENDMENT.1i)

Implants chirurgicaux — Hydroxyapatite —

https://standards.iteh.aPartie_3:Arialyseschimiquesetscaractérisation du rapport de e052d3cristallinitéset de la pureté de phase

AMENDEMENT 1

PROOF/ÉPREUVE



Reference number ISO 13779-3:2018/Amd.1:2021(E)

iTeh STANDARD PREVIEW (standards.iteh.ai)

ISO 13779-3:2018/PRF Amd 1 https://standards.iteh.ai/catalog/standards/sist/b36367e6-bea7-478b-9395-e052d33cc296/iso-13779-3-2018-prf-amd-1



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This document was prepared by Technical Committee ISO/TC 150, *Implants for surgery*, SC 1 *Materials*.

A list of all parts in the ISO 13779 series can be found on the ISO website 395-

e052d33cc296/iso-13779-3-2018-prf-amd-1

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Implants for surgery — Hydroxyapatite —

Part 3:

Chemical analysis and characterization of crystallinity ratio and phase purity

AMENDMENT 1

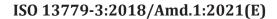
5.8.4

Change the text to the following:

The results shall be given by a dimensionless value representing the Ca:P atomic ratio expressed to the nearest two decimal places.

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